

G2R120MT33J

3300 V 120 mΩ SiC MOSFET

Silicon Carbide MOSFET
N-Channel Enhancement Mode

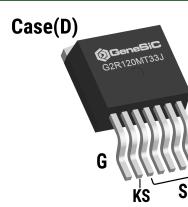


V_{DS}	=	3300 V
$R_{DS(ON)}(\text{Typ.})$	=	120 mΩ
$I_D(T_c = 100^\circ\text{C})$	=	24 A

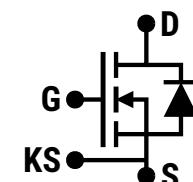
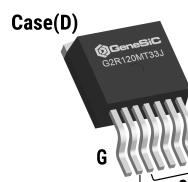
Features

- G2R™ Technology with +20 V Gate Drive
- Superior $Q_G \times R_{DS(ON)}$ Figure of Merit
- Superior Cost-Performance Index
- Low Capacitances and Low Gate Charge
- Fast and Reliable Body Diode
- Low Losses at All Temperatures
- Optimized Package with Separate Driver Source Pin

Package



TO-263-7



D = Drain
G = Gate
S = Source
KS = Kelvin Source



Advantages

- Compatible with Commercial Gate Drivers
- Increased Power Density for Compact System
- High Frequency Switching
- Improved Thermal Capability
- Ease of Paralleling without Thermal Runaway

Applications

- Solar String Inverters
- EV- Fast Chargers
- Pulsed Power
- Switched Mode Power Supply
- Energy Storage
- Solid State Transformers
- Solid State Circuit Breakers

Absolute Maximum Ratings (At $T_c = 25^\circ\text{C}$ Unless Otherwise Stated)

Parameter	Symbol	Conditions	Values	Unit	Note
Drain-Source Voltage	$V_{DS(\text{max})}$	$V_{GS} = 0 \text{ V}, I_D = 100 \mu\text{A}$	3300	V	
Gate-Source Voltage (Dynamic)	$V_{GS(\text{max})}$		-10 / +25	V	
Gate-Source Voltage (Static)	$V_{GS(\text{op})}$	Recommended Operation	-5 / +20	V	
Continuous Forward Current	I_D	$T_c = 25^\circ\text{C}, V_{GS} = -5 / +20 \text{ V}$	34		
		$T_c = 100^\circ\text{C}, V_{GS} = -5 / +20 \text{ V}$	24	A	Fig. 15
		$T_c = 135^\circ\text{C}, V_{GS} = -5 / +20 \text{ V}$	17		
Pulsed Drain Current	$I_{D(\text{pulse})}$	$t_p \leq 3\mu\text{s}, D \leq 1\%, V_{GS} = 20 \text{ V}$, Note 1	100	A	Fig. 14
Power Dissipation	P_D	$T_c = 25^\circ\text{C}$	366	W	Fig. 16
Non-Repetitive Avalanche Energy	E_{AS}	$L = 34.0 \text{ mH}, I_{AS} = 7.5 \text{ A}$	955	mJ	
Operating and Storage Temperature	T_j, T_{stg}		-55 to 175	°C	

Thermal/Package Characteristics

Parameter	Symbol	Conditions	Values			Unit	Note
			Min.	Typ.	Max.		
Thermal Resistance, Junction - Case	R_{thJC}		0.34	0.41		°C/W	Fig. 13
Weight	W_T			1.45		g	

Note 1: Pulse Width t_p Limited by $T_{j(\text{max})}$



Electrical Characteristics (At $T_C = 25^\circ\text{C}$ Unless Otherwise Stated)

Parameter	Symbol	Conditions	Values	Unit	Note
			Min.	Typ.	Max.
Drain-Source Breakdown Voltage	V_{DSS}	$V_{GS} = 0 \text{ V}, I_D = 100 \mu\text{A}$	3300		V
Zero Gate Voltage Drain Current	I_{DSS}	$V_{DS} = 3300 \text{ V}, V_{GS} = 0 \text{ V}$		1	μA
Gate Source Leakage Current	I_{GSS}	$V_{DS} = 0 \text{ V}, V_{GS} = 25 \text{ V}$ $V_{DS} = 0 \text{ V}, V_{GS} = -10 \text{ V}$		100 -100	nA
Gate Threshold Voltage	$V_{GS(\text{th})}$	$V_{DS} = V_{GS}, I_D = 4.0 \text{ mA}$ $V_{DS} = V_{GS}, I_D = 4.0 \text{ mA}, T_j = 175^\circ\text{C}$	2.5 3.40	4.50	V Fig. 9
Transconductance	g_f	$V_{DS} = 10 \text{ V}, I_D = 15 \text{ A}$ $V_{DS} = 10 \text{ V}, I_D = 15 \text{ A}, T_j = 175^\circ\text{C}$		5.8 6.3	S Fig. 4
Drain-Source On-State Resistance	$R_{DS(\text{ON})}$	$V_{GS} = 20 \text{ V}, I_D = 15 \text{ A}$ $V_{GS} = 20 \text{ V}, I_D = 15 \text{ A}, T_j = 175^\circ\text{C}$		120 246	156 $\text{m}\Omega$ Fig. 5-8
Input Capacitance	C_{iss}			3099	
Output Capacitance	C_{oss}			55	pF Fig. 11
Reverse Transfer Capacitance	C_{rss}	$V_{DS} = 1000 \text{ V}, V_{GS} = 0 \text{ V}$ $f = 1 \text{ MHz}, V_{AC} = 25 \text{ mV}$		5.2	
C_{oss} Stored Energy	E_{oss}			36	μJ Fig. 12
C_{oss} Stored Charge	Q_{oss}			108	nC
Gate-Source Charge	Q_{gs}	$V_{DS} = 1000 \text{ V}, V_{GS} = -5 / +20 \text{ V}$		41	
Gate-Drain Charge	Q_{gd}	$I_D = 15 \text{ A}$		43	nC Fig. 10
Total Gate Charge	Q_g	Per IEC607478-4		130	
Internal Gate Resistance	$R_{G(\text{int})}$	$f = 1 \text{ MHz}, V_{AC} = 25 \text{ mV}$		1.3	Ω
Turn-On Switching Energy (Body Diode)	E_{on}	$T_j = 25^\circ\text{C}, V_{GS} = -5/+20 \text{ V}, R_{G(\text{ext})} = 10 \Omega, L = 220.0 \mu\text{H}, I_D = 15 \text{ A}, V_{DD} = 1700 \text{ V}$		501	μJ Fig. 22
Turn-Off Switching Energy (Body Diode)	E_{off}			168	
Turn-On Delay Time	$t_{d(on)}$			96	
Rise Time	t_r			26	
Turn-Off Delay Time	$t_{d(off)}$	$R_{G(\text{ext})} = 10 \Omega, L = 220.0 \mu\text{H}, I_D = 15 \text{ A}$		35	ns Fig. 24
Fall Time	t_f	Timing relative to V_{DS} , Inductive load		16	

Reverse Diode Characteristics

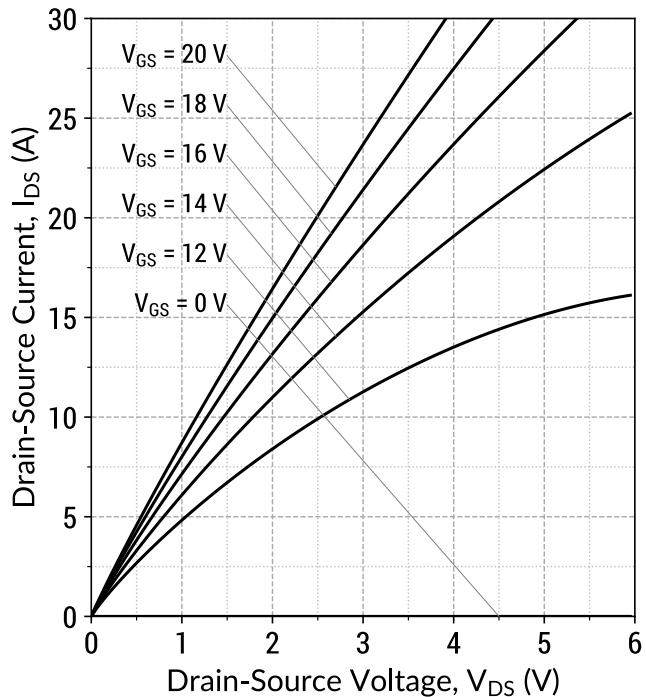
Parameter	Symbol	Conditions	Values	Unit	Note
			Min.	Typ.	Max.
Diode Forward Voltage	V_{SD}	$V_{GS} = -5 \text{ V}, I_{SD} = 7 \text{ A}$ $V_{GS} = -5 \text{ V}, I_{SD} = 7 \text{ A}, T_j = 175^\circ\text{C}$	4.0 3.4		V Fig. 17-18
Continuous Diode Forward Current	I_s	$V_{GS} = -5 \text{ V}, T_c = 100^\circ\text{C}$	29		A
Diode Pulse Current	$I_{s(\text{pulse})}$	$V_{GS} = -5 \text{ V}$, Note 1		116	A
Reverse Recovery Time	t_{rr}	$V_{GS} = -5 \text{ V}, I_{SD} = 15 \text{ A}, V_R = 1700 \text{ V}$		72	ns
Reverse Recovery Charge	Q_{rr}	$dif/dt = 500 \text{ A}/\mu\text{s}, T_j = 25^\circ\text{C}$		340	nC
Peak Reverse Recovery Current	I_{rrm}			8	A
Reverse Recovery Time	t_{rr}	$V_{GS} = -5 \text{ V}, I_{SD} = 15 \text{ A}, V_R = 1700 \text{ V}$		95	ns
Reverse Recovery Charge	Q_{rr}	$dif/dt = 500 \text{ A}/\mu\text{s}, T_j = 175^\circ\text{C}$		1305	nC
Peak Reverse Recovery Current	I_{rrm}			18	A

*The chip technology was characterized up to 200 V/ns. The measured dV/dt was limited by measurement test setup and package.



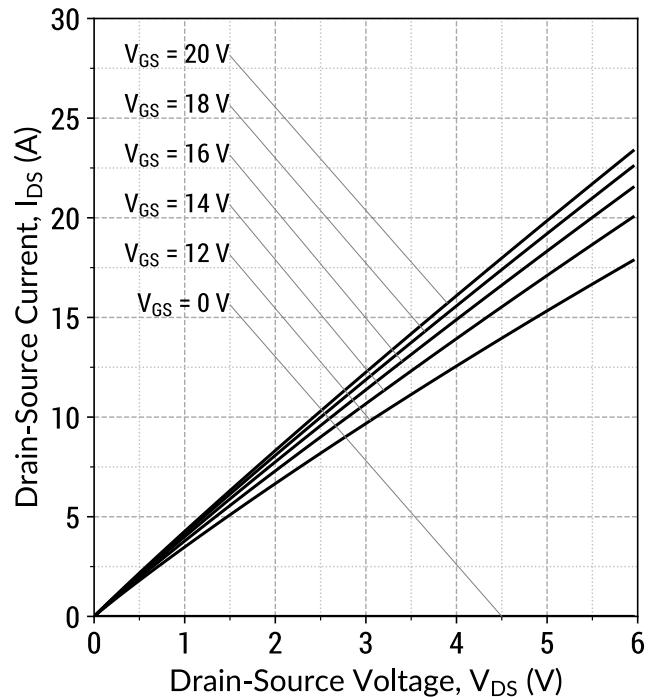
G2R120MT33J
3300 V 120 mΩ SiC MOSFET

Figure 1: Output Characteristics ($T_j = 25^\circ\text{C}$)



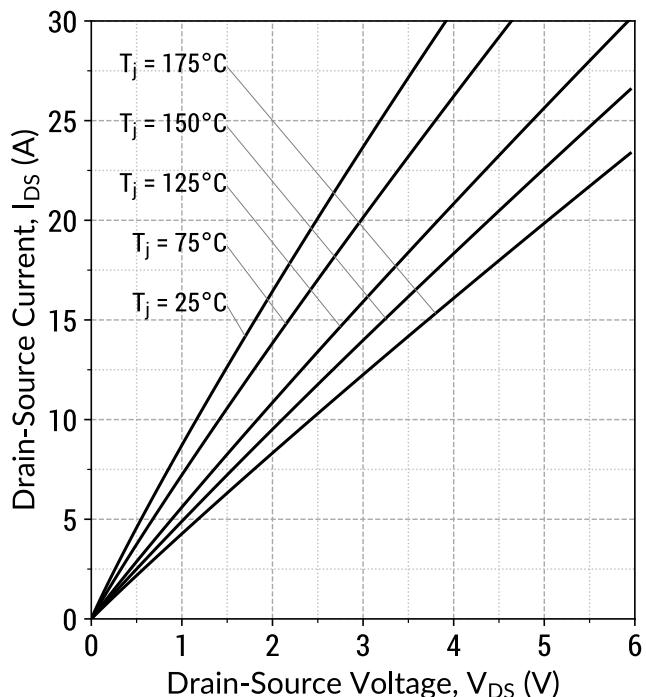
$$I_D = f(V_{DS}, V_{GS}); t_P = 250 \mu\text{s}$$

Figure 2: Output Characteristics ($T_j = 175^\circ\text{C}$)



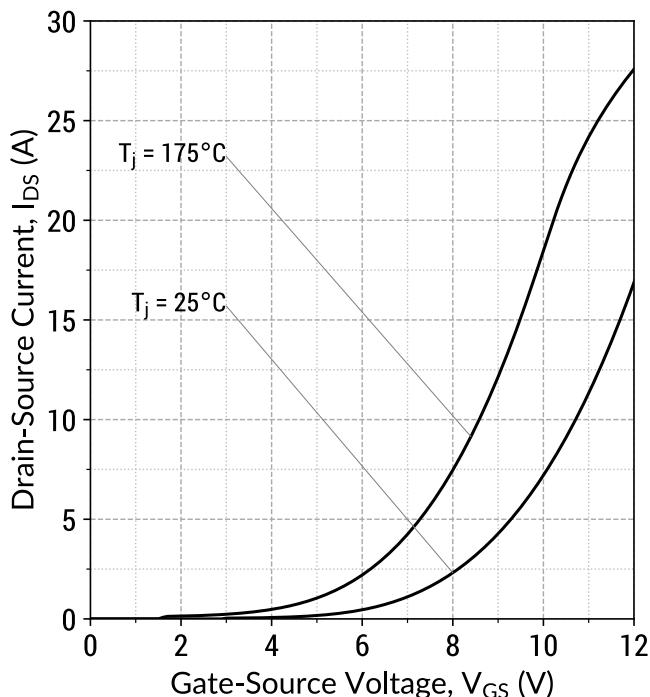
$$I_D = f(V_{DS}, V_{GS}); t_P = 250 \mu\text{s}$$

Figure 3: Output Characteristics ($V_{GS} = 20 \text{ V}$)



$$I_D = f(V_{DS}, T_j); t_P = 250 \mu\text{s}$$

Figure 4: Transfer Characteristics ($V_{DS} = 10 \text{ V}$)

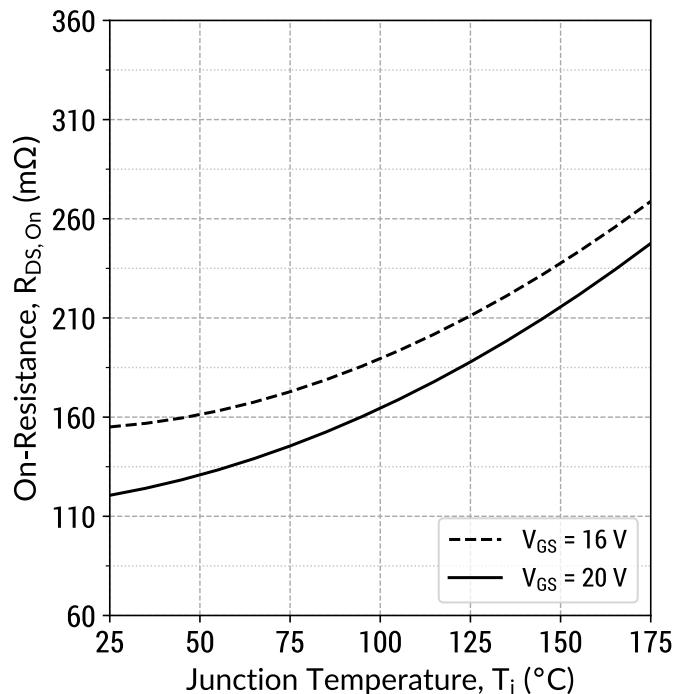


$$I_D = f(V_{GS}, T_j); t_P = 100 \mu\text{s}$$

G2R120MT33J
3300 V 120 mΩ SiC MOSFET

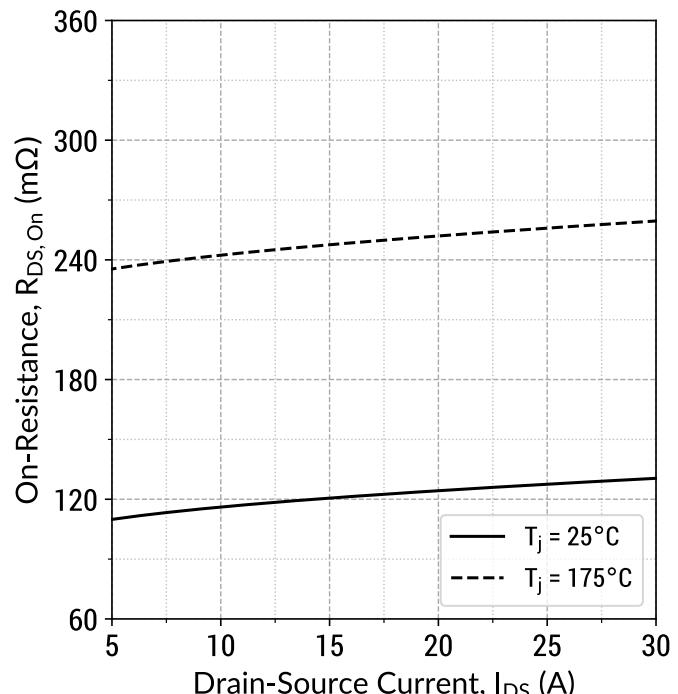


Figure 5: On-State Resistance v/s Temperature



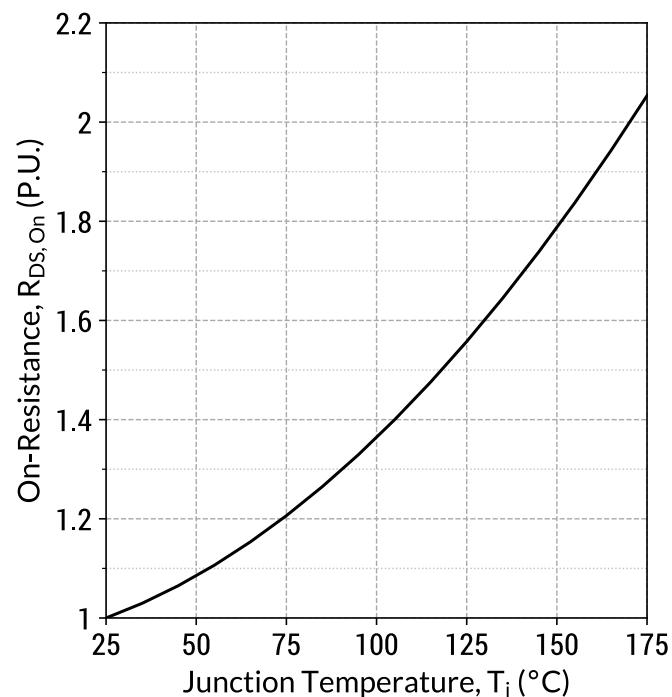
$$R_{DS(ON)} = f(T_j, V_{GS}); t_p = 250 \mu\text{s}; I_D = 15 \text{ A}$$

Figure 6: On-State Resistance v/s Drain Current



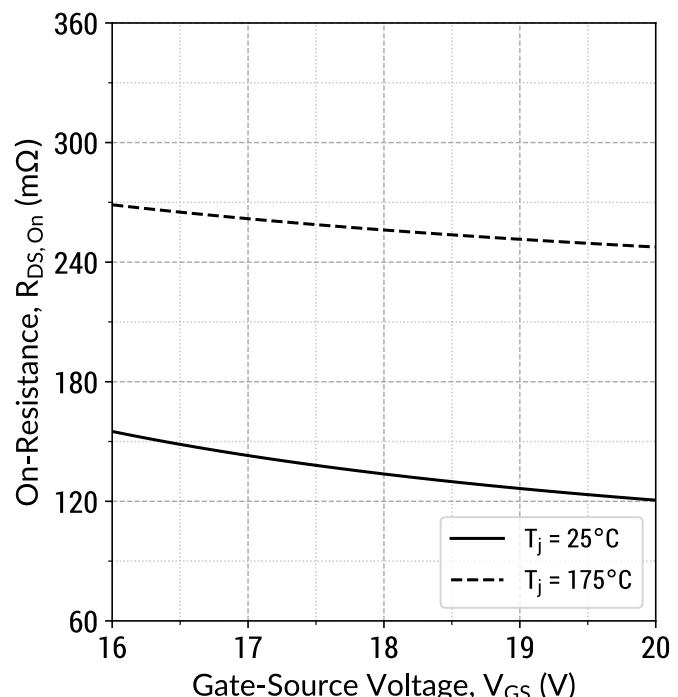
$$R_{DS(ON)} = f(T_j, I_{DS}); t_p = 250 \mu\text{s}; V_{GS} = 20 \text{ V}$$

Figure 7: Normalized On-State Resistance v/s Temperature



$$R_{DS(ON)} = f(T_j); t_p = 250 \mu\text{s}; I_D = 15 \text{ A}; V_{GS} = 20 \text{ V}$$

Figure 8: On-State Resistance v/s Gate Voltage



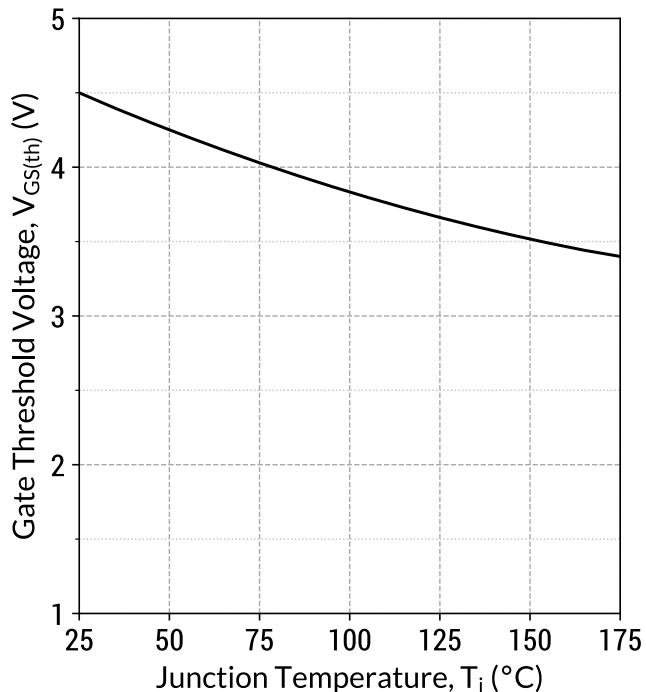
$$R_{DS(ON)} = f(T_j, V_{GS}); t_p = 250 \mu\text{s}; I_D = 15 \text{ A}$$



G2R120MT33J
3300 V 120 mΩ SiC MOSFET

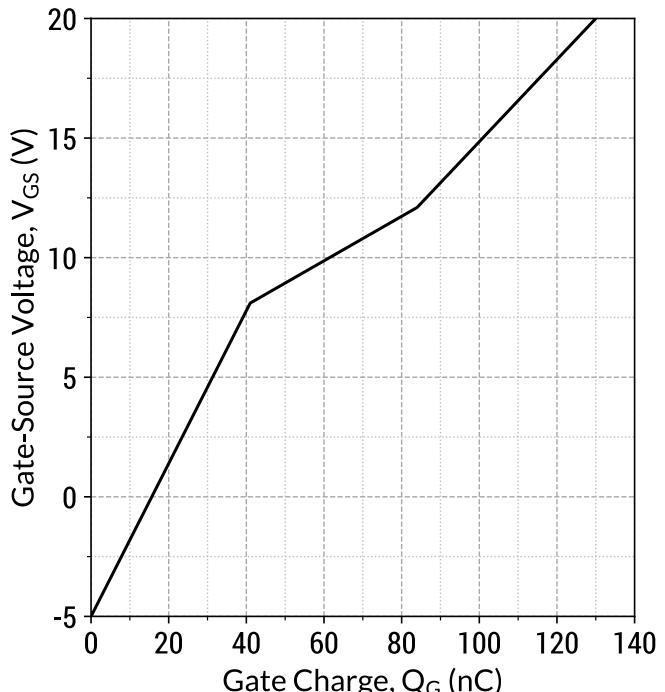


Figure 9: Threshold Voltage Characteristics



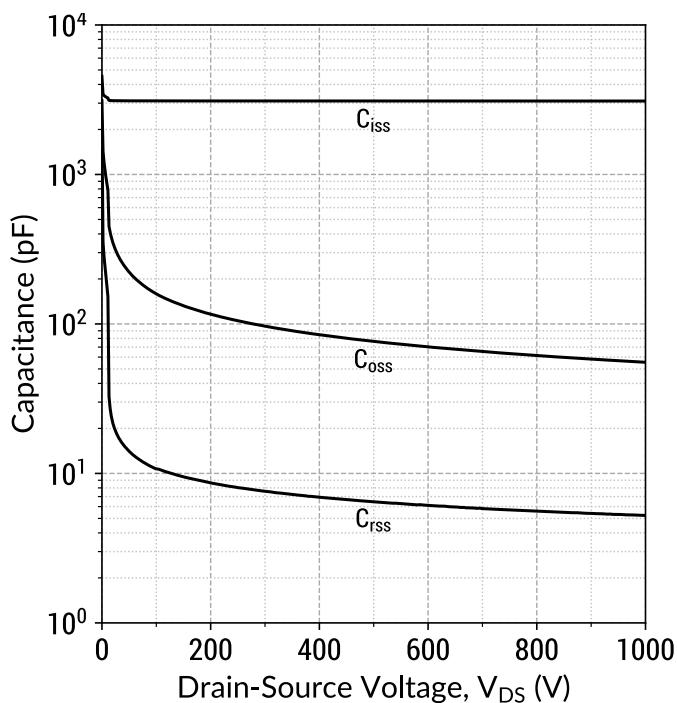
$V_{GS(th)} = f(T_j); V_{DS} = V_{GS}; I_D = 4.0 \text{ mA}$

Figure 10: Gate Charge Characteristics



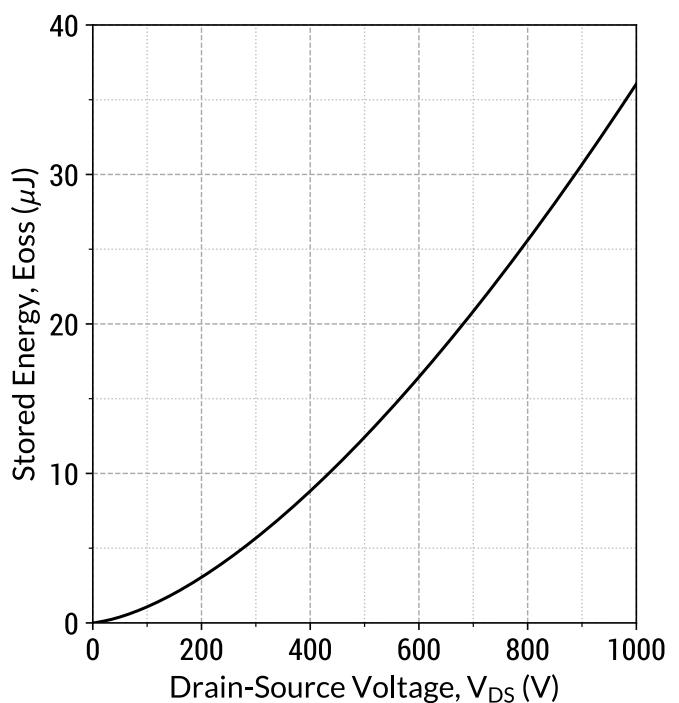
$I_D = 15 \text{ A}; V_{DS} = 1000 \text{ V}; T_c = 25^\circ\text{C}$

Figure 11: Capacitance v/s Drain-Source Voltage



$f = 1 \text{ MHz}; V_{AC} = 25 \text{ mV}$

Figure 12: Output Capacitor Stored Energy



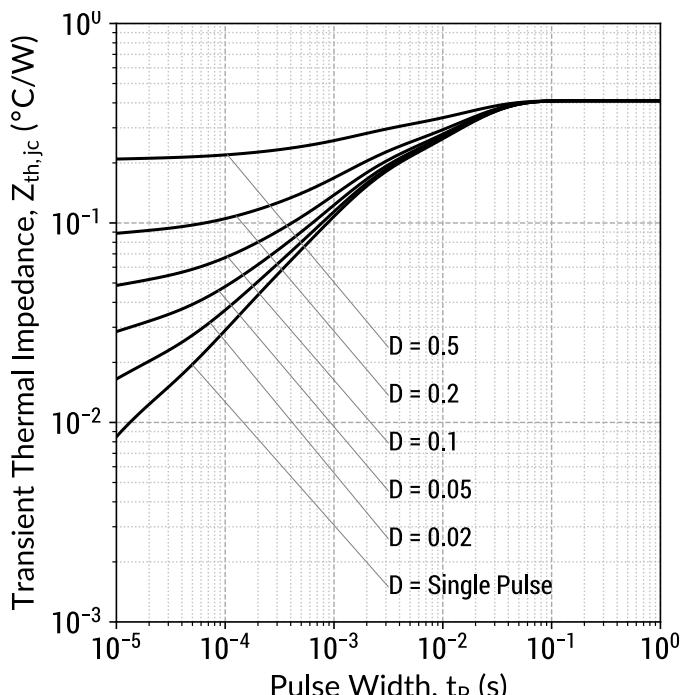
$E_{oss} = f(V_{DS})$



G2R120MT33J
3300 V 120 mΩ SiC MOSFET

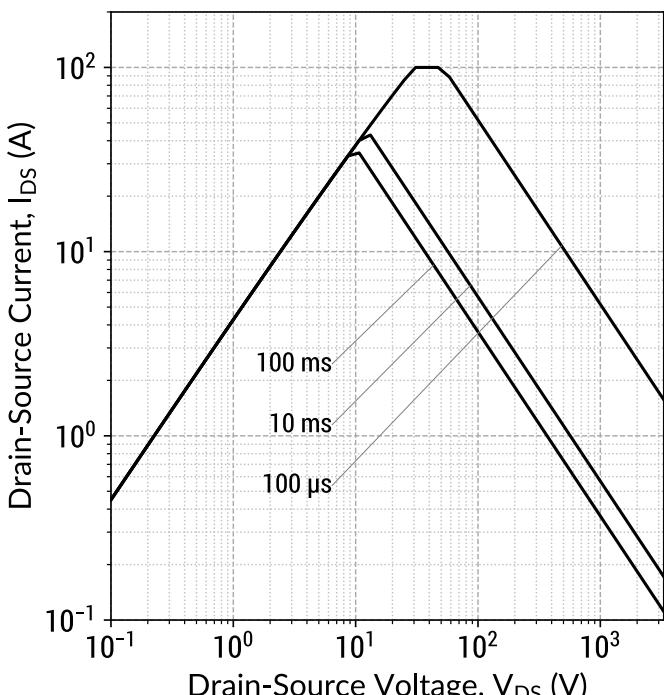


Figure 13: Transient Thermal Impedance



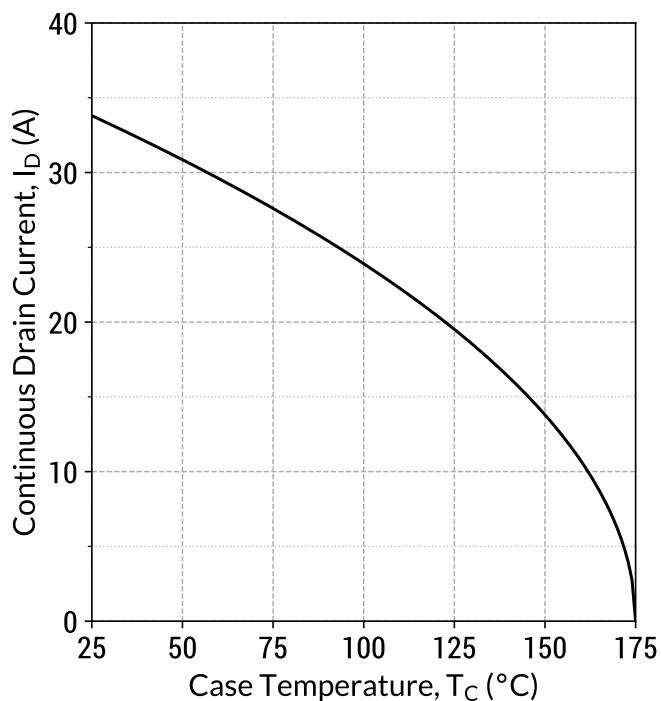
$$Z_{th,ic} = f(t_P, D); D = t_P/T$$

Figure 14: Safe Operating Area ($T_c = 25^{\circ}\text{C}$)



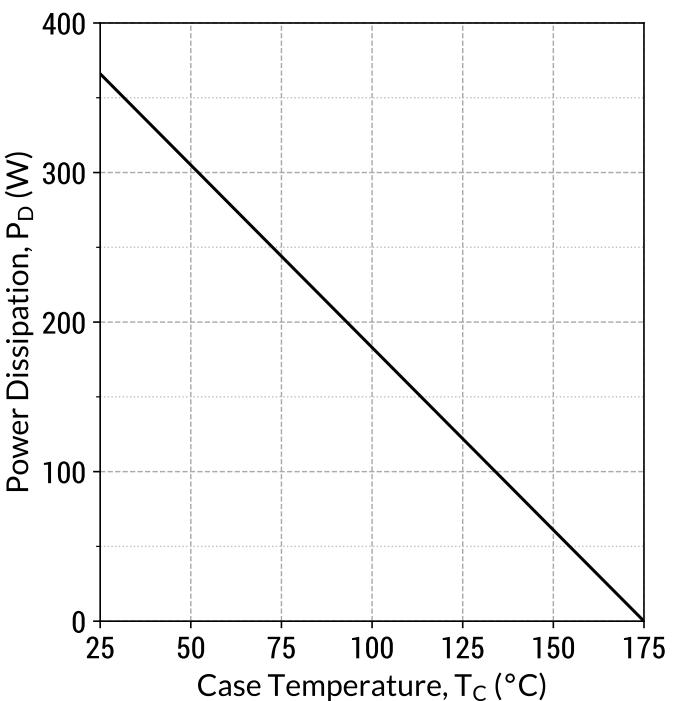
$$I_D = f(V_{DS}, t_P); T_j \leq 175^{\circ}\text{C}; D = 0$$

Figure 15: Current De-rating Curve



$$I_D = f(T_C); T_j \leq 175^{\circ}\text{C}$$

Figure 16: Power De-rating Curve

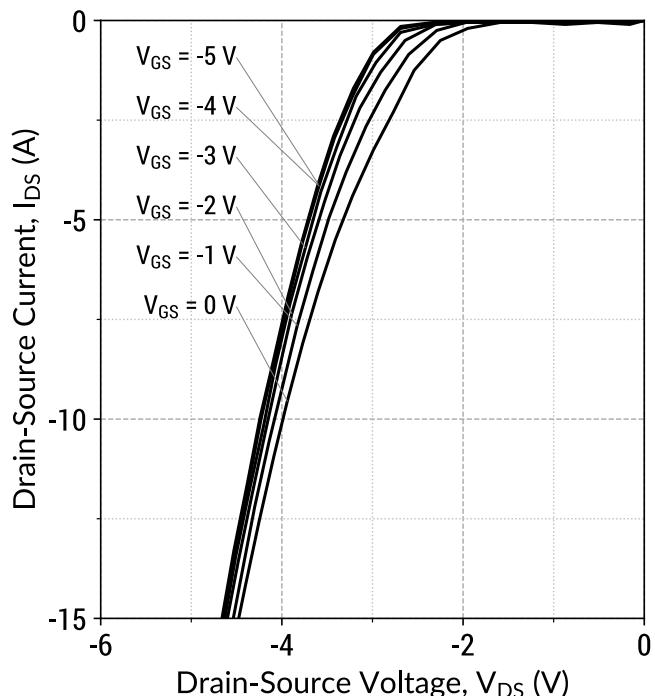


$$P_D = f(T_C); T_j \leq 175^{\circ}\text{C}$$



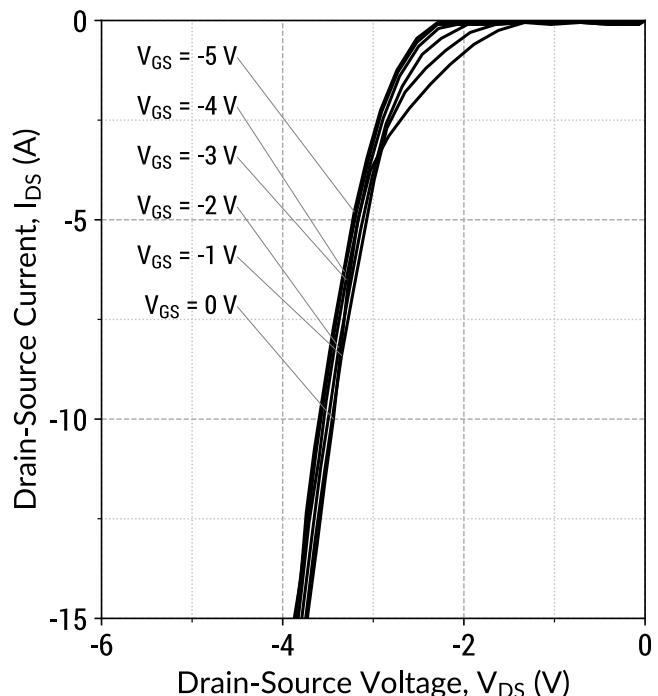
G2R120MT33J
3300 V 120 mΩ SiC MOSFET

Figure 17: Body Diode Characteristics ($T_J = 25^\circ\text{C}$)



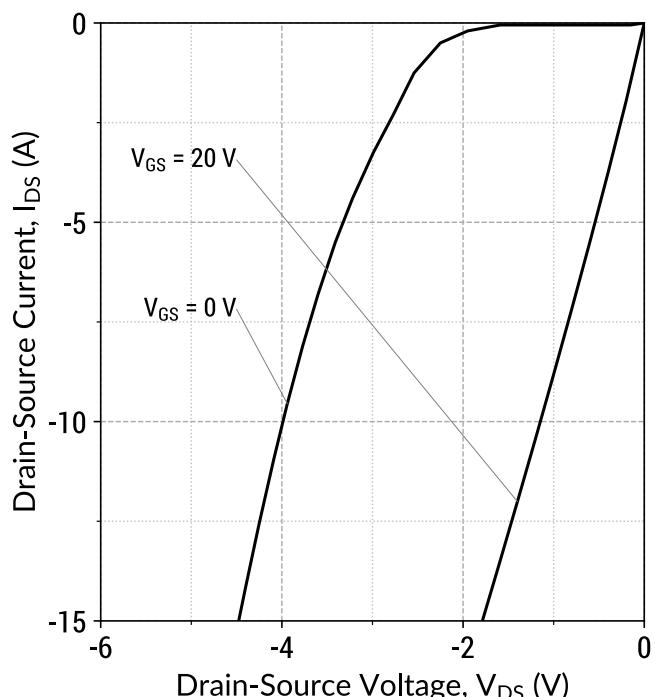
$$I_D = f(V_{DS}, V_{GS}); t_P = 250 \mu\text{s}$$

Figure 18: Body Diode Characteristics ($T_J = 175^\circ\text{C}$)



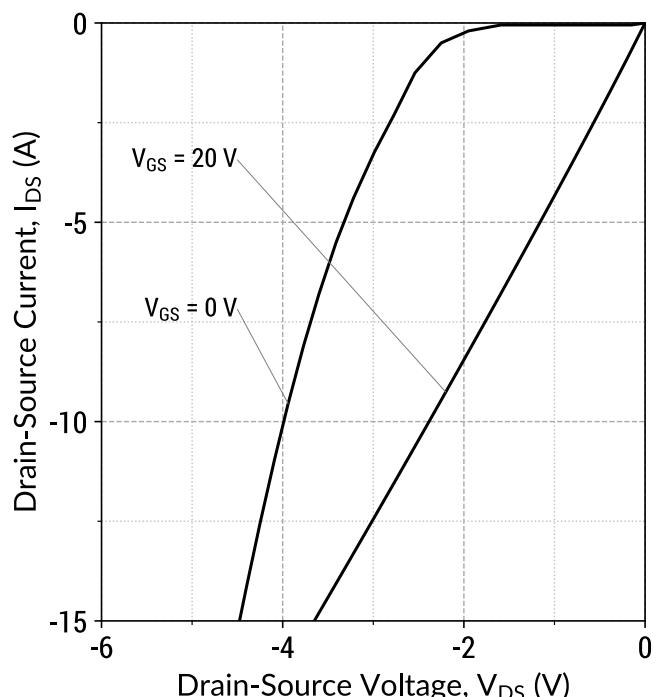
$$I_D = f(V_{DS}, V_{GS}); t_P = 250 \mu\text{s}$$

Figure 19: Third Quadrant Characteristics ($T_J = 25^\circ\text{C}$)



$$I_D = f(V_{DS}, V_{GS}); t_P = 250 \mu\text{s}$$

Figure 20: Third Quadrant Characteristics ($T_J = 175^\circ\text{C}$)

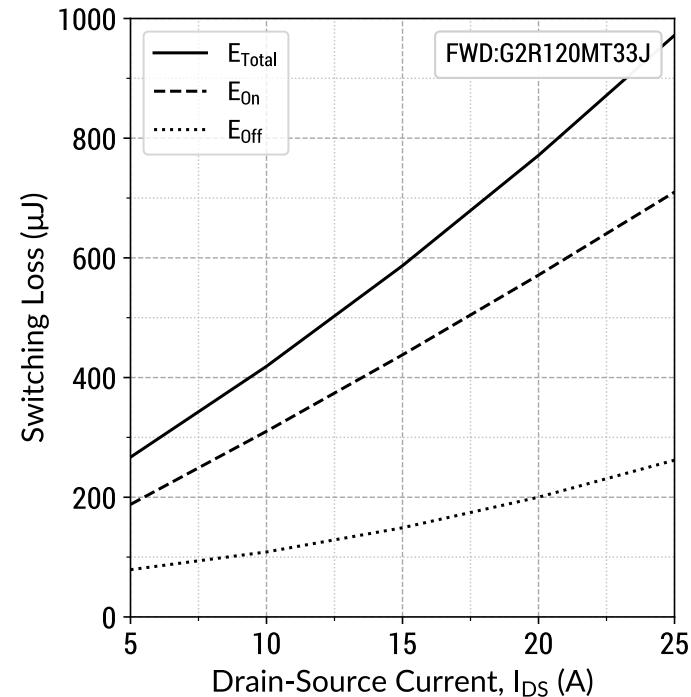


$$I_D = f(V_{DS}, V_{GS}); t_P = 250 \mu\text{s}$$

G2R120MT33J

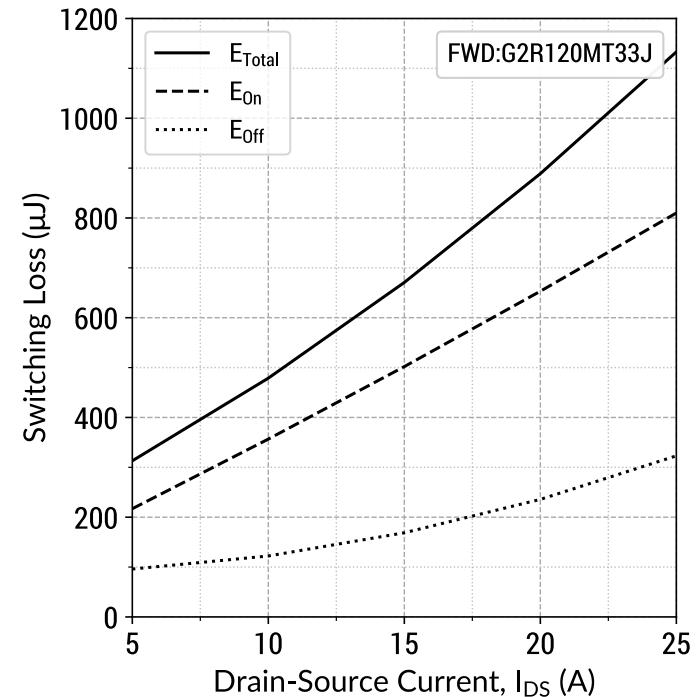
3300 V 120 mΩ SiC MOSFET

Figure 21: Inductive Switching Energy v/s Drain Current
($V_{DD} = 1500V$)



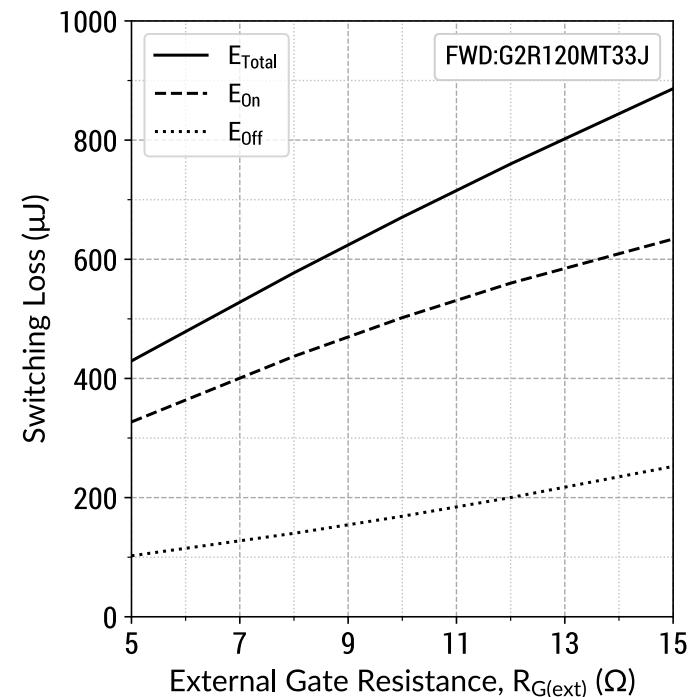
$T_j = 25^\circ C; V_{GS} = -5/+20V; R_{G(ext)} = 10 \Omega; L = 220.0\mu H$

Figure 22: Inductive Switching Energy v/s Drain Current
($V_{DD} = 1700V$)



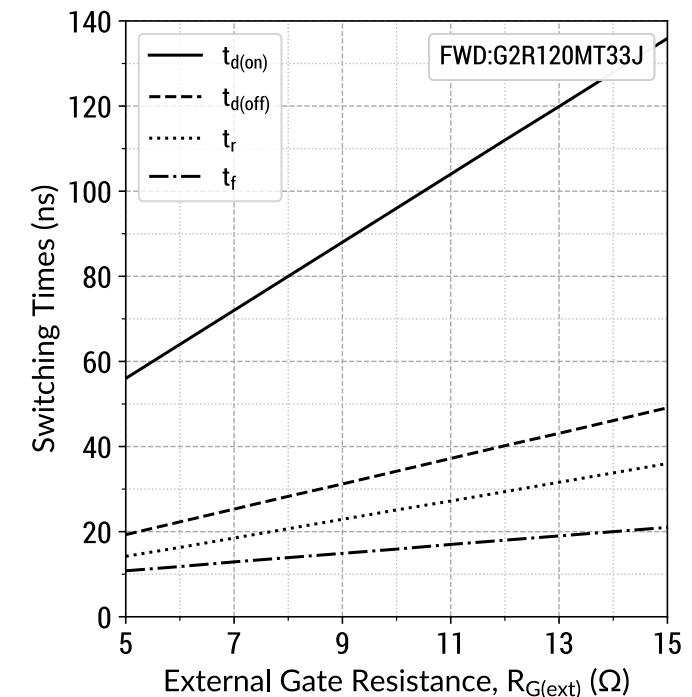
$T_j = 25^\circ C; V_{GS} = -5/+20V; R_{G(ext)} = 10 \Omega; L = 220.0\mu H$

Figure 23: Inductive Switching Energy v/s $R_{G(ext)}$
($V_{DD} = 1700V$)



$T_j = 25^\circ C; V_{GS} = -5/+20V; I_{DS} = 15 A; L = 220.0\mu H$

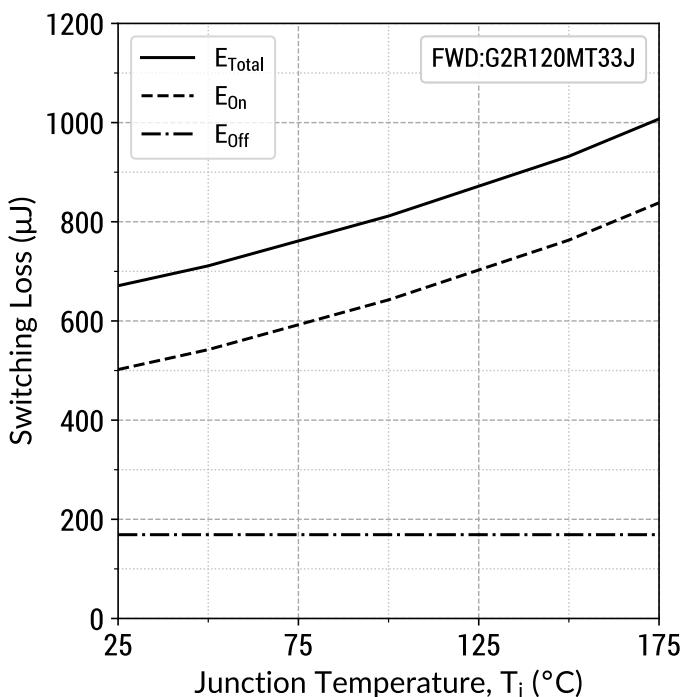
Figure 24: Switching Time v/s $R_{G(ext)}$
($V_{DD} = 1700V$)



$T_j = 25^\circ C; V_{GS} = -5/+20V; I_{DS} = 15 A; L = 220.0\mu H$

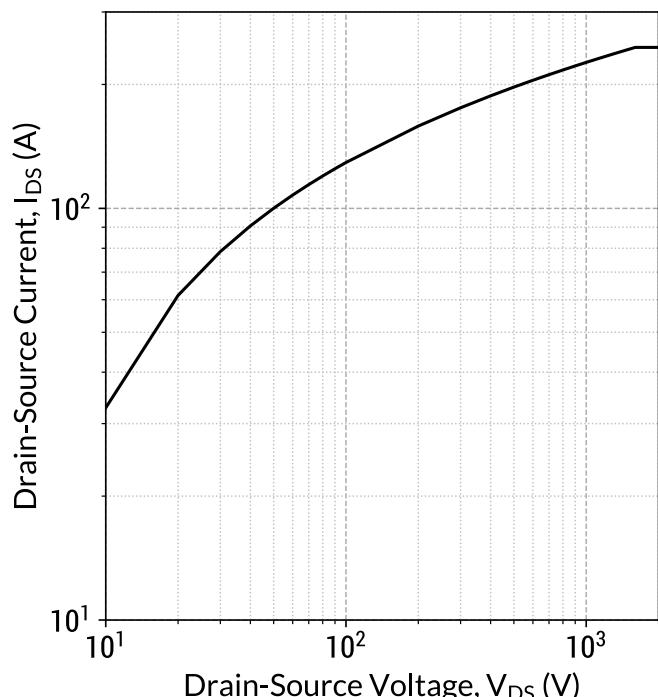
G2R120MT33J
3300 V 120 mΩ SiC MOSFET

**Figure 25: Inductive Switching Energy v/s Temperature
($V_{DD} = 1700V$)**



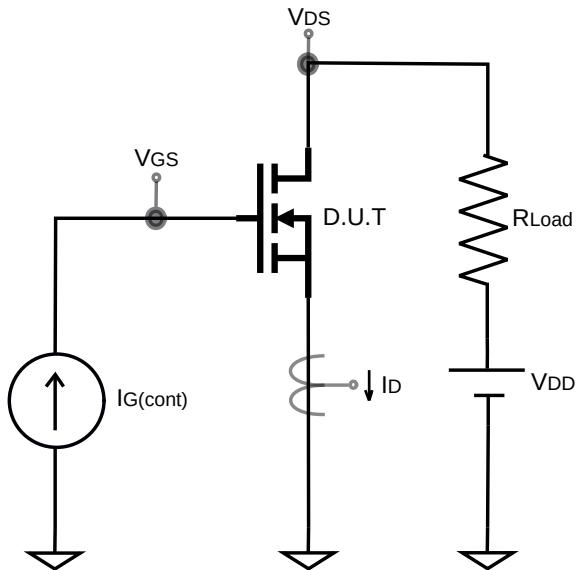
$T_j = 25^{\circ}\text{C}$; $V_{GS} = -5/+20\text{V}$; $R_{G(ext)} = 10 \Omega$; $I_{DS} = 15 \text{A}$; $L = 220.0\mu\text{H}$

Figure 26: High Current IV

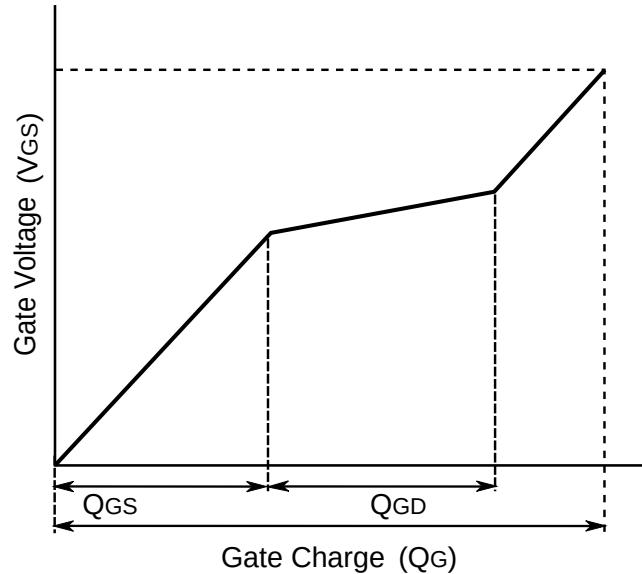


$I_D = f(V_{DS})$; $t_P \leq 3 \mu\text{s}$; $V_{GS} = 20 \text{V}$

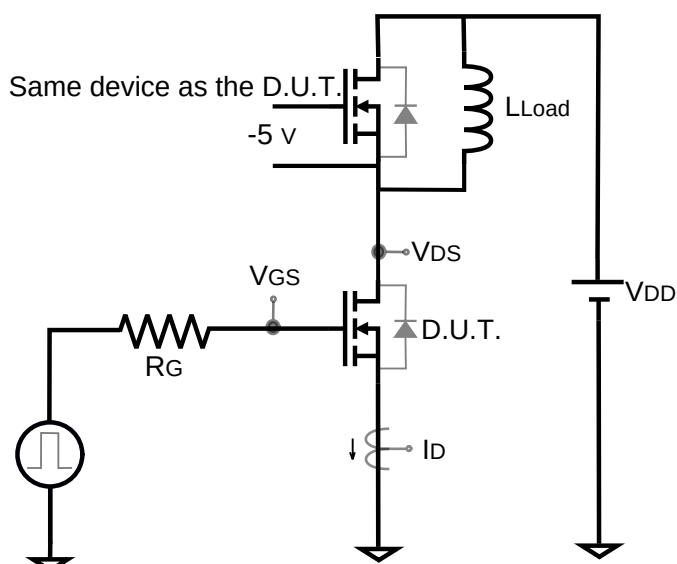
Gate Charge Circuit



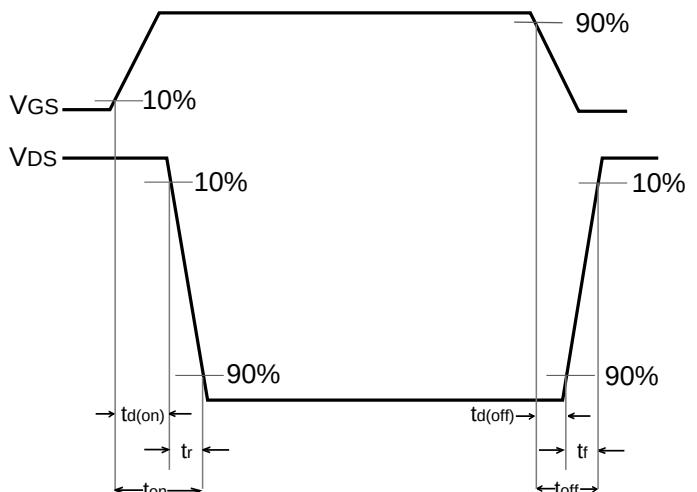
Gate Charge Waveform



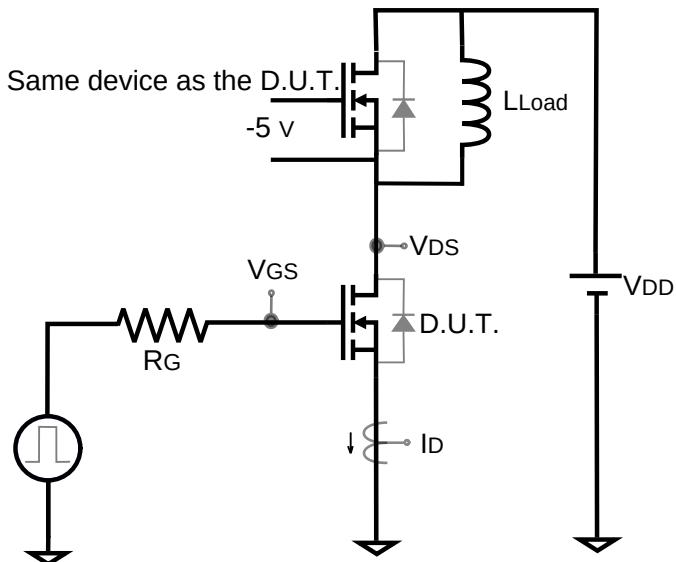
Switching Time Circuit



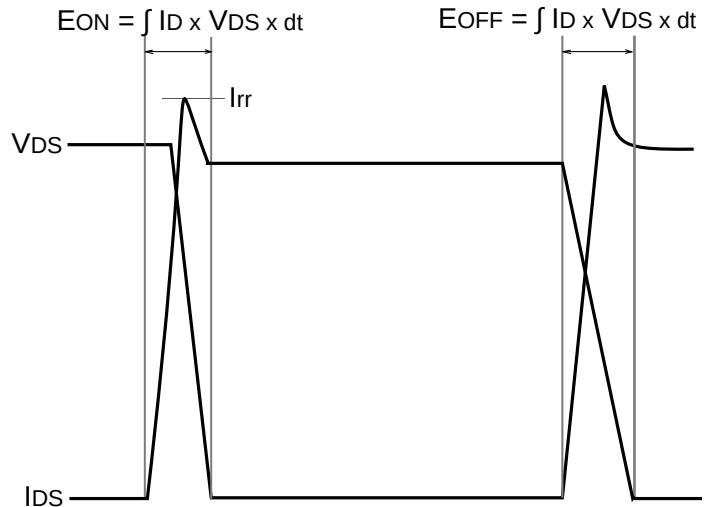
Switching Time Waveform



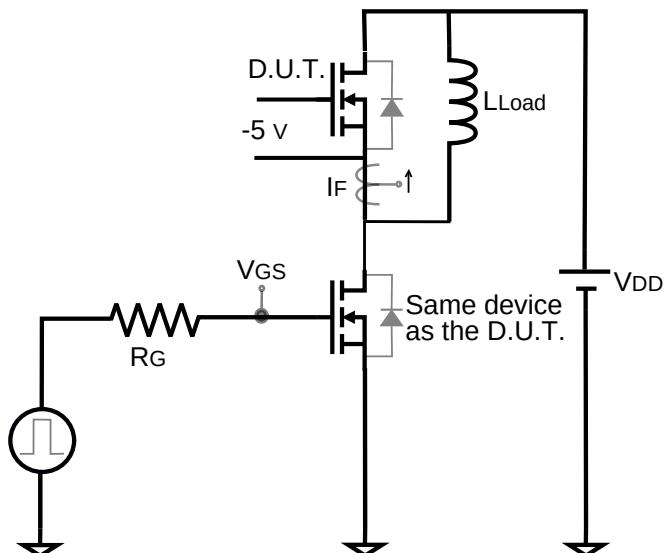
Switching Energy Circuit



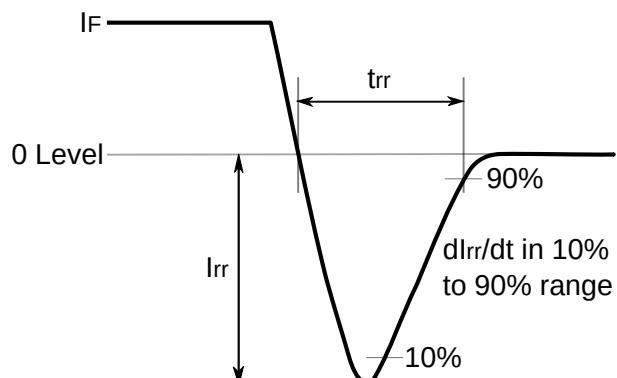
Switching Energy Waveform



Reverse Recovery Circuit

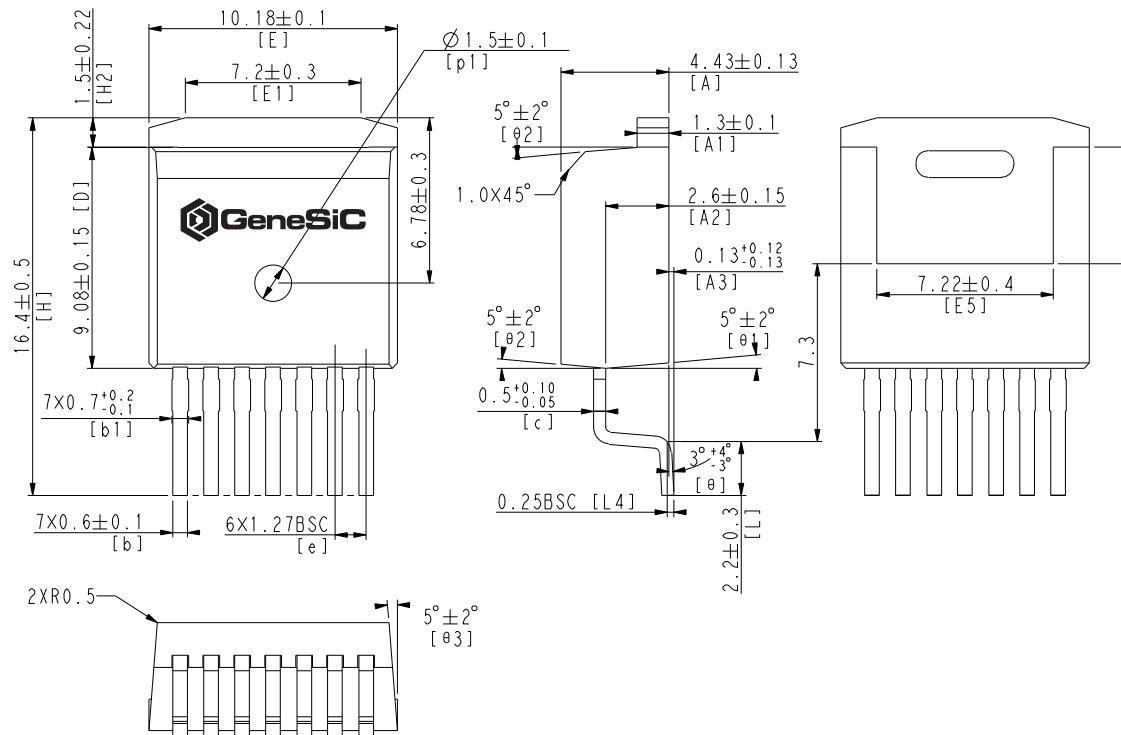


Reverse Recovery Waveform

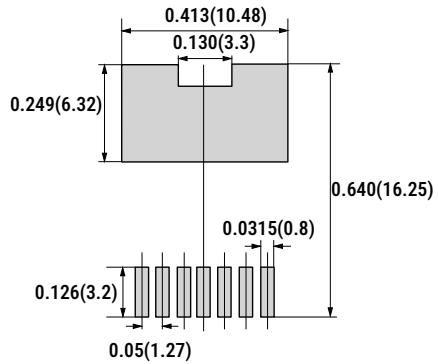


Package Dimensions

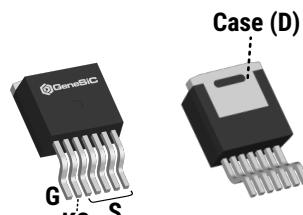
TO-263-7 Package Outline



Recommended Solder Pad Layout



Package View



NOTE

1. CONTROLLED DIMENSION IS INCH. DIMENSION IN BRACKET IS MILLIMETER.
2. DIMENSIONS DO NOT INCLUDE END FLASH, MOLD FLASH, MATERIAL PROTRUSIONS.
3. THE SOURCE AND KELVIN-SOURCE PINS ARE NOT INTERCHANGABLE. THEIR EXCHANGE MIGHT LEAD TO MALFUNCTION.

Compliance

RoHS Compliance

The levels of RoHS restricted materials in this product are below the maximum concentration values (also referred to as the threshold limits) permitted for such substances, or are used in an exempted application, in accordance with EU Directive 2011/65/EC (RoHS 2), as adopted by EU member states on January 2, 2013 and amended on March 31, 2015 by EU Directive 2015/863. RoHS Declarations for this product can be obtained from your GeneSiC representative.

REACH Compliance

REACH substances of high concern (SVHCs) information is available for this product. Since the European Chemical Agency (ECHA) has published notice of their intent to frequently revise the SVHC listing for the foreseeable future, please contact a GeneSiC representative to insure you get the most up-to-date REACH SVHC Declaration. REACH banned substance information (REACH Article 67) is also available upon request.

Disclaimer

GeneSiC Semiconductor, Inc. reserves right to make changes to the product specifications and data in this document without notice. GeneSiC disclaims all and any warranty and liability arising out of use or application of any product. No license, express or implied to any intellectual property rights is granted by this document.

Unless otherwise expressly indicated, GeneSiC products are not designed, tested or authorized for use in life-saving, medical, aircraft navigation, communication, air traffic control and weapons systems, nor in applications where their failure may result in death, personal injury and/or property damage.

Related Links

- SPICE Models: https://www.genesicsemi.com/sic-mosfet/G2R120MT33J/G2R120MT33J_SPICE.zip
- PLECS Models: https://www.genesicsemi.com/sic-mosfet/G2R120MT33J/G2R120MT33J_PLECS.zip
- CAD Models: https://www.genesicsemi.com/sic-mosfet/G2R120MT33J/G2R120MT33J_3D.zip
- Gate Driver Reference: <https://www.genesicsemi.com/technical-support>
- Evaluation Boards: <https://www.genesicsemi.com/technical-support>
- Reliability: <https://www.genesicsemi.com/reliability>
- Compliance: <https://www.genesicsemi.com/compliance>
- Quality Manual: <https://www.genesicsemi.com/quality>

Revision History

- Rev 21/Jan: Updated with most recent test data
- Supersedes: Rev 20/Nov



www.genesicsemi.com/sic-mosfet/